

EL 465855441

Inventor: Vladimir S gal et al.

Title: Methods of Forming Aluminum-Comprising Physical Vapor  
Deposition Targets; Sputtered Films; and Target  
Constructions

Assignee: Honeywell International Inc.

Serial No.: Filed herewith

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**INFORMATION DISCLOSURE STATEMENT**

**PURSUANT TO 37 C.F.R. §§ 1.56, 1.97 AND 1.98**

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, the Examiner's attention is directed to the references listed on the attached Form PTO-1449 and copies of which are attached. No admission is made regarding whether all the submitted references are prior art.

Citation of these references is respectfully requested.

Respectfully submitted,

Date: 2/13/01

Attorney: \_\_\_\_\_

A handwritten signature in black ink, appearing to read "David G. Latwesen".

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